Reg. No.:					

Question Paper Code: 59043

B.E. / B.Tech. DEGREE EXAMINATION, NOV 2017

Elective

Electronics and Communication Engineering

15UEC919 - NANO ELECTRONICS

		(Regula	ation 2015)					
Du	ration: Three hours		M	Iaximum: 100 Marks				
		Answer A	LL Questions					
		PART A - (5	$5 \times 1 = 5 \text{ Marks}$					
1.	Kind of electron microscope which is used to study internal structure of cells is							
	(a) scanning e(c) light micro	electron microscope scope	(b) Transmission(d) Compound mic	electron microscope croscope				
2.	conceptualized carbon nano-tubes?							
	(a) Richard Sr	nalley	(b) Albert Einstein	ı				
	(c) Issac Newt	on	(d) Richard Feynman					
3.	Who introduced the term 'Nucleic acids'?							
(a) Meisher			(b) Robert Brown	(b) Robert Brown				
(c) Lipmann			(d) Altmann					
4.	Which of the follo materials?	wing is an example of	bottom-up approach for the	e preparation of nano				
	(a) Etching (c) Lithograph	y	(b) Dip pen nano-lithography(d) Erosion					
5.	The size of a quantum dot is nm.							
	(a) 5	(b) 10	(c) 50	(d) 100				
		PART - B (5	x 3 = 15 Marks)					
6.	What is the working	ng principle of Raman	Spectroscopy.					

Give any two excellent properties of carbon nanotubes.

What is meant by DNA computer?

9.	Wh	at is the process of photolithography?	
10.	Lis	t the applications of quantum dots.	
		PART - C (5 x $16 = 80 \text{ Marks}$)	
11.	(a)	Explain the importance of considering higher angle(2θ) reflections while anal the XRD patterns.	yzing (16)
		Or	
	(b)	Explain the various steps involved in sample preparation route for TEM.	(16)
12.	(a)	Discuss in detail about Carbon Nanotube Fabrication, Structure and Properties.	(16)
		Or	
	(b)	With neat sketch explain the applications of Carbon Nanotubes.	(16)
13.	(a)	Discuss the fundamental advanced silicon MOSFET concepts in nanoelectronic	s. (16)
		Or	
	(b)	With neat sketch, design and explain the working of OLED.	(16)
14.	(a)	Explain in detail about Modular design approaches for product development.	(16)
		Or	
	(b)	Briefly discuss about the concepts of photolithography.	(16)
15.	(a)	Explain the concepts of CVD.	(16)
		Or	
	(b)	Describe in detail about Giant and Colossal magneto resistance.	(16)